-Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S15 0	449	"5,186,718"	US-PGPUB; USPAT	OR .	OFF	2006/12/15 14:38
S15 1	0	"5,186,718.PN. and cluster adj tool"	US-PGPUB; USPAT	OR	OFF	2006/12/15 09:33
S15 2	0	("5,186,718.PN." and (cluster adj tool))	US-PGPUB; USPAT	OR	OFF	2006/12/15 09:33
S15 3	3071	(cluster adj tool)	US-PGPUB; USPAT	OR	OFF	2006/12/15 09:33
S15 4	3	(cluster adj tool and (align\$3 with mask and magnet))	US-PGPUB; USPAT	OR	ON	2006/12/15 10:06
S15 5	0	Hongmwi near Zhang.IN.	US-PGPUB; USPAT	OR ·	ON	2006/12/15 10:07
S15 6	0	Hongmwi near Zhang.IN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 10:07
S15 7	16	Hongmei near Zhang.IN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 10:08
S15 8	71	Richard near Demaray.IN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 10:33
\$15 9	959	Deposition with cluster adj tool	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 10:33
S16 0	5	(Deposition with cluster adj tool and (alignment adj mechanism))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 10:34

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S16 1	159	(Deposition with cluster adj tool and (align\$3 with mask))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 10:38
S16 2	1	(sputter adj Deposition with sputter adj cluster adj tool and (align\$3 with mask))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 10:39
S16 3	0	(Shunpei near Yamazaki.IN. and · (align\$3 with mask)with cluster adj tools)	US-PGPUB; USPAT	OR	OFF	2006/12/15 10:42
S16 4	0	(Shunpei near Yamazaki.IN. and (align\$3 with mask)and (cluster adj tools))	US-PGPUB; USPAT	OR	OFF	2006/12/15 10:42
S16 5	1928	"5,186,718"and (separate adj mechanism)	US-PGPUB; USPAT	OR ·	OFF	2006/12/15 11:31
S16 6	173	"5,186,718"and (separating adj mask and substrate)	US-PGPUB; USPAT	OR	OFF	2006/12/15 14:09
S16 7	241516	(separating adj mask and substrate by separate adj mechanism)	US-PGPUB; USPAT	OR	OFF	2006/12/15 11:36
S16 8	111	(Deposition adj chambers and(separating adj mask and substrate by separate adj mechanism))	US-PGPUB; USPAT	OR	OFF	2006/12/15 11:36
S16 9	0	("lcd" "eld" electroluminescen\$4)and(align\$3 with mask and magnet)with (separate adj mechanism)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/12/15 11:44
S17 0	0	("lcd" "eld")and(align\$3 with mask and magnet)with (separate adj mechanism)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR .	OFF	2006/12/15 11:45

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S17 1		magnet)with (separate adj mechanism))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB		OFF	2006/12/15 12:23
S17 2	3312991	((substrate and mask separated by separate adj mechanism))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB		OFF	2006/12/15 12:24
S17 3	51	(deposition adj chambers with (substrate and mask separated by separate adj mechanism))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/12/15 12:24
S17 4	2719	(Shunpei near Yamazaki.IN. and (align\$3 without mask))	US-PGPUB; USPAT	OR	OFF	2006/12/15 14:06
S17 5	22	(118/719.ccls. 118/720.ccls. 118/721.ccls.) and ("lcd" "eld" electroluminescen\$4)and (support adj member)	US-PGPUB; USPAT	OR	OFF .	2006/12/15 14:07
S17 6	. 0	S175 and S174	US-PGPUB; USPAT	OR	OFF	2006/12/15 14:06
S17 7	4061527	(align\$3 without mask)	US-PGPUB; USPAT	OR	OFF	2006/12/15 14:08
S17 8	20786	"5,186,718"and (align\$3 with mask and substrate)	US-PGPUB; USPAT	OR ·	OFF.	2006/12/15 14:10
S17 9	155	(organic adj layers and (align\$3 with mask and substrate))	US-PGPUB; USPAT	OR	OFF	2006/12/15 16:27
S18 0	28235	(organic adj layers and (align\$3 without mask and substrate))	US-PGPUB; USPAT	OR	OFF	2006/12/15 14:11
S18 1	28293	(organic adj layers and (align\$3 without mask))	US-PGPUB; USPAT	OR	OFF	2006/12/15 14:11
S18 . 2	3684	(organic adj layers and (align\$3 with no mask))	US-PGPUB; USPAT	OR	OFF	2006/12/15 14:11
S18 3	667	alignment adj chamber	US-PGPUB; USPAT	OR	OFF	2006/12/15 15:15

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S1 4		18	Robert near Begin.IN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 15:16
S1 5	.8	0	(organic adj layers and (align\$3 with mask and substrate)with cluster adj tool)	US-PGPUB; USPAT	OR	OFF	2006/12/15 16:28
S1 6	8	3	(organic adj layers and (align\$3 with mask and substrate)and (cluster adj tool))	US-PGPUB; USPAT	OR	OFF	2006/12/15 16:28
S18	8	3	(organic adj layers and (align\$3 with mask and substrate)and (cluster adj tool))	US-PGPUB; USPAT	OR	ON	2006/12/15 16:29
S18 8			(organic adj layers and (align\$3 with mask and substrate)and (cluster adj tool))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 16:29
S18	3	. 187	(organic adj layers and (align\$3 with mask and substrate)and (chambers))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 16:31
S19 0		336	(organic adj layers and (align\$3 with substrate)and (chambers))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 16:42
S19 1		4	(organic adj layers and (separating adj mask)and (chambers))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR ·	ON	2006/12/15 16:42
\$19 2		5 5:00:09 PM		US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/15 16:43

S19 3	19	(vacuum adj chambers and (separating adj mask and substrate))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON .	2006/12/15 16:43
S19 4	70	(Shunpei near Yamazaki.IN. and (align\$3 with mask)and chambers)	US-PGPUB; USPAT	OR	OFF	2006/12/21 12:09
S19 5	5	10-214682	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2006/12/21 12:10
S19 6	0	10-214682	EPO; JPO; DERWENT	OR	OFF	2006/12/21 12:10
S19 7	5	"10214682"	EPO; JPO; DERWENT	OR	OFF	2006/12/21 13:26
S19 8	3	"2001089841"	EPO; JPO; DERWENT	OR	OFF	2006/12/21 13:26

12/21/2006 5:00:08 PM C:\Documents and Settings\vbernard\My Documents\EAST\Workspaces\App# 10796527.wsp